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Inventor Information for 10/800710

Inventor Name	City	State/Country
HANAZAKI, MINORU	HYOGO	JAPAN

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US 20050253277 A1	20051117	Film for protecting mother glass for flat panel display and use thereof	257/778		Yamanaka, Takeshi et al.
US 20050253276 A1	20051117	Film for protecting mother glass for flat panel display and use thereof	257/778		Yamanaka, Takeshi et al.
US 20050201953 A1	20050915	Antibacterial flavor and fragrance composition and halitosis-inhibition flavor and fragrance composition and oral care composition containing the same	424/58		Hanada, Minoru et al.
US 20050201646 A1	20050915	Foil hydrodynamic journal bearing and method of manufacturing the same	384/106		Nagata, Mari et al.
US 20050194253 A1	20050908	Coating film-forming method	204/500		Hanatani, Minoru et al.
US 20040182311 A1	20040923	Semiconductor processing apparatus having semiconductor wafer mounting	118/663		Hanazaki, Minoru
US 20040180951 A1	20040916	Antibacterial agent	514/457		Hiramoto, Tadahiro et al.
US 20040164866	20040826	Attack deterrent and	340/573.1	340/574	Hanabusa, Russell Minoru

A1		attacker identification system			et al.
US 20040161472 A1	20040819	Methods of judging mouth odor	424/537		Sakurai, Kazutoshi et al.
US 20040075563 A1	20040422	Attack deterrent and attacker identification system	340/574		Hanabusa, Russell Minvoru et al.
US 20040066299 A1	20040408	Attack deterrent and attacker identification system	340/574	340/573.1	Hanabusa, Russell Minoru et al.
US 20030202946 A1	20031030	Antimicrobial flavor and oral care composition containing the same	424/49	424/439	Hanada, Minoru et al.
US 20030178140 A1	20030925	Plasma processing apparatus capable of evaluating process performance	156/345.28	118/712	Hanazaki, Minoru et al.
US 20030117701 A1	20030626	Microscope	359/368	359/391	Hanaoka, Minoru
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US 20030056899 A1	20030327	Semiconductor processing apparatus and manufacturing method of semiconductor device	156/345.25	156/345.24	Hanazaki, Minoru
US 20030046976 A1	20030313	Gas analyzing method and gas analyzer for semiconductor	73/23.21	118/715; 118/723R; 156/345.24; 438/14	Hanazaki, Minoru et al.

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US 20030039616 A1	20030227	Antimicrobial flavor and oral care composition containing the same	424/49		Hanada, Minoru et al.
US 20020177621 A1	20021128	Antifungal fragrance composition	514/461	514/693; 514/699; 514/730; 514/739	Hanada, Minoru et al.
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US 20020002950 A1	20020110	WAFER PROCESSING APPARATUS	118/724	118/728	TSUCHIHASHI, MASAAKI et al.
US 6960350 B2	20051101	Antifungal fragrance composition	424/404	422/28; 422/32; 422/36; 424/405; 424/406; 424/408; 424/409; 424/411; 424/43; 424/46; 428/34.1; 428/35.2; 428/35.4; 428/35.5; 428/35.7; 428/36.1; 428/36.2; 428/36.6; 512/2; 512/20; 512/21; 512/22; 512/23; 512/24; 512/25; 512/26; 512/27; 512/5; 514/957	Hanada; Minoru et al.

US 6929712 B2	20050816	Plasma processing apparatus capable of evaluating process performance	156/345.28	118/712; 118/723E; 118/723ER; 118/728; 156/345.24; 156/345.25; 156/345.43; 156/345.47; 204/298.39; 315/111.01; 315/111.21; 315/111.31; 315/111.61	Hanazaki; Minoru et al.
US 6898006 B2	20050524	Microscope	359/390	359/389	Hanaoka; Minoru
US 6864982 B2	20050308	Gas analyzing method and gas analyzer for semiconductor treater	356/437		Hanazaki; Minoru et al.
US 6723501 B2	20040420	Methods of judging mouth odor	435/4		Sakurai; Kazutoshi et al.
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US 6416618 B2	20020709	Wafer processing apparatus	156/345.51	118/723E; 118/725; 118/728; 156/345.24; 156/345.52	Tsuchihashi; Masaaki et al.
US 6410034 B1	20020625	Dermal absorption-promoting agent	424/401	424/403; 424/405; 514/724; 514/729; 514/738; 514/739; 514/827; 514/828; 514/829; 514/830; 514/844; 514/889; 514/918	Matsumoto; Mitsuo et al.
US 6384074 B1	20020507	Cell growth activating composition	514/510		Tamai; Eiko et al.

		containing compound having labdane structure			
US 6313214 B1	20011106	Melanin inhibiting and cell growth activating compositions containing compounds having labdane structure	524/529	514/569	Tamai; Eiko et al.
US 6287980 B1	20010911	Plasma processing method and plasma processing apparatus	438/726	156/345.28; 156/345.29; 216/69; 438/728; 438/732	Hanazaki; Minoru et al.
US 6280754 B1	20010828	Dermal topical formulations	424/401	424/62; 514/946; 514/947	Hanada; Minoru et al.
US 6273023 B1	20010814	Plasma processing apparatus capable of reliably, electrostatically attracting and holding and thus fixing semiconductor wafer	118/723E	118/712; 156/345.28; 156/345.43; 156/345.51	Tsuchihashi; Masaaki et al.
US 6218196 B1	20010417	Etching apparatus, etching method, manufacturing method of a semiconductor device, and semiconductor device	438/689	257/E21.311	Ise; Hirotooshi et al.
US 6121343 A	20000919	Perfume-containing controlled	523/102	424/78.37	Hongo; Hideyuki et al.

		release biodegradable resin composition			
US 6109208 A	20000829	Plasma generating apparatus with multiple microwave introducing means	118/723MA	118/723MW; 156/345.42; 204/298.08; 204/298.38	Tsuchihashi; Masaaki et al.
US 6054016 A	20000425	Magnetically enhanced microwave plasma generating apparatus	156/345.42	118/723MR	Tuda; Mutumi et al.
US 6033780 A	20000307	Fine particles of petaloid porous hydroxyapatite and process for producing the same	428/402	106/122; 106/672; 106/682; 106/816	Nishioka; Hidehiko et al.
US 6024105 A	20000215	Semiconductor manufacturing device and method of removing particles therefrom	134/1.3	134/104.1; 134/902; 156/345.29; 438/905; 438/906	Hanazaki; Minoru et al.
US 5976687 A	19991102	Additive for synthetic resins and a synthetic resin composition	428/323	428/408; 428/409	Nishioka; Hidehiko et al.
US 5844022 A	19981201	Additive for synthetic resins and synthetic resin compositions	523/218	428/403; 428/847.6; 521/54	Nishioka; Hidehiko et al.
US 5494651 A	19960227	Method for manufacturing monodisperse vaterite type calcium	423/432		Minayoshi; Shiro et al.

		carbonate			
US 5409993 A	19950425	Fluid gasket composition	525/104	525/100; 525/105; 525/106; 525/403; 525/446; 525/453; 525/474; 525/477	Kojima; Kazuhiro et al.
US 5397812 A	19950314	Adhesive composition consisting of microcapsules containing compounds dispersed in a binder	522/13	522/100; 522/103; 522/14; 522/170; 522/173; 522/175; 522/182; 522/24; 523/176	Usami; Ikuzo et al.
US 5352308 A	19941004	Self-locking agent	156/66	156/330; 156/71; 156/92; 428/355R; 428/402.2	Tomihara; Kenichi et al.
US 5339304 A	19940816	Optical disc having two-step pit structure and pickup apparatus	369/109.02	369/275.1; 369/275.4	Hanaoka; Minoru
US 5275651 A	19940104	Monodisperse vaterite type calcium carbonate, its manufacturing method and method of controlling growth of particles and shape thereof	106/464	423/432	Minayoshi; Shiro et al.
US 5107280 A	19920421	Divisional exposure apparatus	347/235	250/235; 347/237; 359/212	Ohashi; Tsuyoishi et al.
US 5071957 A	19911210	Antibiotic BU-4061T	530/330	549/548	Konishi; Masataka et al.
US 4990448	19910205	Bu-4061T	435/106	435/252.1;	Konishi;

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US 4947085 A	19900807	Plasma processor	315/111.41	118/50.1; 118/723MR; 156/345.42; 204/298.37	Nakanishi; Koichiro et al.
US 4894510 A	19900116	Apparatus for uniformly distributing plasma over a substrate	219/121.43	156/345.42; 204/192.1; 204/298.37; 219/121.42	Nakanishi; Koichiro et al.
US 4834700 A	19890530	Method of and apparatus for forming filter element	493/463	264/324; 493/456; 493/457; 493/470; 493/941	Kondo; Naohiko et al.
US 4725318 A	19880216	Filler for paper-making and neutral paper-making process by the use thereof	106/465	106/464; 162/181.1; 162/181.2	Minayoshi; Shiro et al.
US 4504580 A	19850312	Antibiotics produced by fermentation of a novel strain of Streptomyces hygroscopicus	435/74	435/253.5; 435/898	Hanada; Minoru et al.
US 4468386 A	19840828	1-Deamino-1- hydroxy- aminoglycoside compounds, antibacterial compositions and method of use	514/39	435/82; 435/83; 536/13.2; 536/13.3; 536/16.6; 536/16.8	Hanada; Minoru et al.
US 4026766 A	19770531	Fermentation process	435/71.1	435/822	Tomita; Koji et al.
US 4009237 A	19770222	Process for producing shaped synthetic resin articles varying in shape of longitudinal	264/46.1	264/145; 264/163; 264/167; 264/321; 264/45.5; 264/46.7; 264/DIG.14	Kimura; Takashi et al.

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US 3495951 A	19700217	SCREW REACTOR [TEXT AVAILABLE IN USOCR DATABASE]	422/205	165/86; 165/88; 165/89; 165/91; 165/94; 422/198; 422/210; 422/229	HONJYO TAHIKO et al.
US 3450505 A	19690617	REACTOR OF THE TUBULAR TYPE [TEXT AVAILABLE IN USOCR DATABASE]	422/189	366/149; 422/202; 560/190; 568/949	TANAKA HOZUMI et al.